

Electronic Patent Application Fee Transmittal

Application Number:	10727746			
Filing Date:	03-Dec-2003			
Title of Invention:	Chemical vapor deposition reactor			
First Named Inventor/Applicant Name:	Heng Liu			
Filer:	Alma Levy/Jean Heuler			
Attorney Docket Number:	M-15626-1D US			
Filed as Small Entity				
Utility under 35 USC 111(a) Filing Fees				
Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Basic Filing:				
Pages:				
Claims:				
Miscellaneous-Filing:				
Petition:				
Patent-Appeals-and-Interference:				
Post-Allowance-and-Post-Issuance:				
Extension-of-Time:				

Description	Fee Code	Quantity	Amount	Sub-Total in USD(\$)
Miscellaneous:				
Request for continued examination	2801	1	405	405
Total in USD (\$)				405